

Prediction of critical micelle concentration of cationic surfactants using connectivity indices

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Abstract Relationship for predicting Log cmc for cationic surfactants having chloride as counterion from only molecular connectivity indices was found. It is suggested that the index ${}^0\chi^v$ includes some information about hydrophobicity while indices ${}^4\chi_{pc}$ and ${}^4\chi_{vc}^v$ include some information about hydrophilicity of the cationic surfactants studied. The structures of 23 compounds used for the correlation are quite diverse.

Keywords Cationic surfactants · Chloride · QSPR · cmc · Molecular connectivity indices

Abbreviations and Symbols

QSPR	Quantitative Structure—Property Relationship
cmc	Critical micelle concentration
r	Correlation coefficient
F	Fisher ratio value
${}^m\chi$	Connectivity index m -th order
${}^m\chi^v$	Valence connectivity index m -th order
δ_i	Connectivity degree
δ_i^v	Valence connectivity degree
Z^v	Number of valence electrons
Z	Total number of electrons in the i -th atom
h	Number of hydrogen atoms

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1 Introduction

Cationic surfactants are widely used in various fields of industry and biology because they show good bactericidal properties and they are innocuous for human beings and animals. Quaternary ammonium salts are typical cationic surfactants. Their utility results from their anti-electrostatic and anti-corrosion properties, and in particular from their anti-microbial properties with respect to a large spectrum of bacteria, alga and viruses.

The critical micelle concentration (*cmc*) is the most useful parameter for characterizing surfactants. The *cmc* is defined as the concentration at which molecules begin to aggregate to form micelles. During this process many important physicochemical properties such as surface tension, conductivity and detergency change significantly. These properties are important for many industrial and biological systems, therefore predicting the critical micelle concentration directly from the structure of a molecule by quantitative structure-property relationship (QSPR) analysis is of great interest. The first correlation was given by Klevens [1] who empirically found that logarithm of *cmc* linearly decreases with increasing length of an alkyl chain. Recently, the QSPR was used for predicting the *cmc* values of nonionic surfactants [2–5], anionic surfactants [5–8] and cationic surfactants [9]. In papers [2,3,10] molecular connectivity indices together with another topological descriptors are correlated with *cmc* values.

Molecular connectivity indices have been widely used as molecular structural descriptors because they are rich in structural information. In our study we use ten indices: five connectivity indices and five valence connectivity indices, from zeroth to fourth order in both cases. These topological descriptors contain some information about the molecule. Kier and Hall [11] stated that ${}^0\chi$ and ${}^0\chi^v$ include information about atoms contained in a molecule; information about molecular volume and molecular surface area is encoded in the ${}^1\chi$ and ${}^1\chi^v$ indices; ${}^2\chi$ indices carry an information about three-atom fragments which are the minimum number necessary to describe a plane; an information about the number of branch points in the molecule could be contained in ${}^3\chi_c$; the indices ${}^4\chi_{pc}$ and ${}^4\chi_{pc}^v$ include information about the number of ring substituents, the length of the substituents and the heteroatom type of substituent. Therefore, these descriptors have been successfully used to correlate and to predict the physicochemical properties that depend on structure of the molecule.

In a previous paper [12] we derived the relationship between Log cmc and molecular connectivity indices for nonionic surfactants. Using the set of descriptors listed above we have obtained the relationship that contains four indices: ${}^1\chi$, ${}^1\chi^v$, ${}^4\chi_{pc}^v$ and ${}^0\chi$. The previous QSPR study shows that surfactants properties, especially the critical micelle concentration, can be predicted on the basis of molecular structure by using the molecular connectivity indices only. Continuing our work, we decided to correlate Log *cmc* of cationic surfactants with topological indices too. To the best of our knowledge it is for the first time. Admittedly, M. Jalali-Heravi and E. Konouz [9] also correlated Log *cmc* of some quaternary ammonium salts with topological descriptors, but they used topological descriptors as well as the electronic parameters of the total energy of the molecule.

The critical micelle concentration depends not only on geometrical factors but also on a number of other parameters, among them a kind of counterion and electrostatic

Table 1 Experimental values of *cmc* of compounds study

Code	Name of Compound	<i>cmc</i> (mM) [Ref.]
CnTAC	<i>N</i> -alkyl- <i>N</i> , <i>N</i> , <i>N</i> -trimethylammonium chlorides (<i>n</i> = 10, 12, 14, 16, 18)	61 [13], 21 [14], 4.5 [13], 1.4, 0.35 [15]
DDAC	<i>N</i> -dodecyl- <i>N</i> , <i>N</i> -dimethylammonium chloride	15.8 [16]
C _n AC	dodecylamine hydrochlorides (<i>n</i> = 8, 10, 12)	200, 48 [1], 13.5 [16]
C _n BEC	betaine chloride alkyl esters (<i>n</i> = 10, 12, 14, 16)	18, 5.5, 1.9, 0.33 [17]
DMePC	<i>N</i> -dodecyl- <i>N</i> -methylpiperidinium chloride	20 [14]
DMeMC	<i>N</i> -dodecyl- <i>N</i> -methylmorpholinium chloride	21 [14]
C _n APC	<i>N</i> -alkyl-pyridinium chlorides (<i>n</i> = 12, 16, 18)	15, 0.9, 0.24 [13]
1-nPiC	<i>N</i> -alkoxycarbonylmethyl- <i>N</i> -alkyl-piperidinium chlorides (<i>n</i> = 8, 10, 12)	118, 21, 5.5 [17]
ONAC	<i>N</i> -octylnicotinamide chloride	220 [18]
DNAC	<i>N</i> -dodecynicotinamide chloride	12.4 [18]

charge distribution. Therefore, in order to minimize the influence of factors other than geometrical on *cmc* we took into account only cationic surfactants with chloride as counterion. However, the structures of the compounds are significantly different.

2 Data

The data set was chosen to contain only cationic surfactants, especially quaternary ammonium chloride salts. Literature data for *cmc* are given in Table 1. All values of *cmc* were measured in pure water at 25°C.

The chemical structures of the surfactants taken into consideration and their abbreviations are shown in Fig. 1.

3 Method

3.1 Connectivity indices (χ) and valence connectivity indices (χ^v)

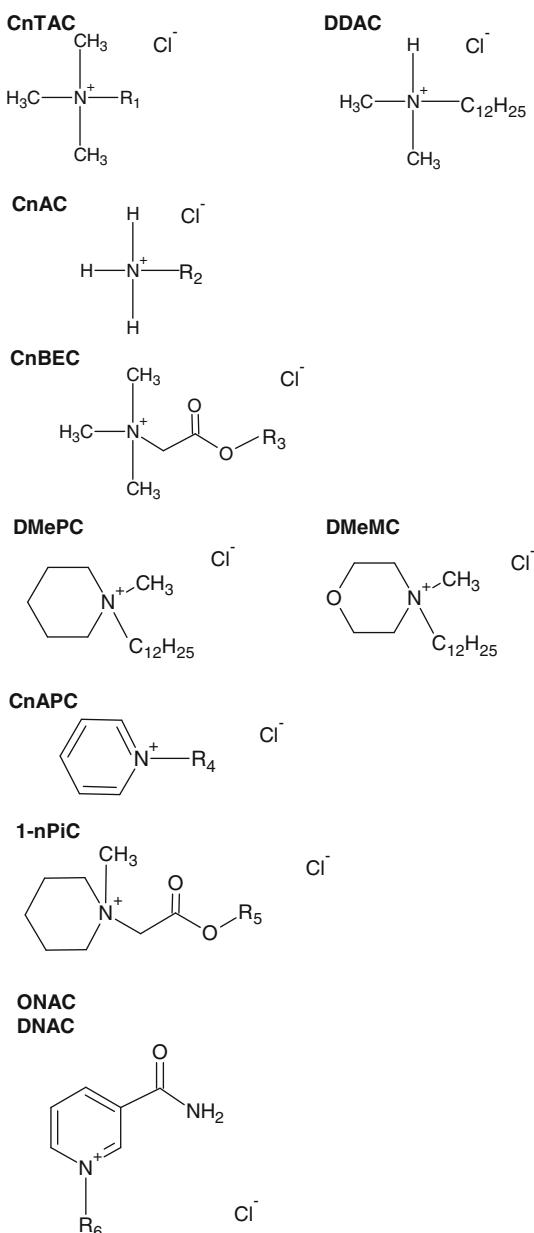
The connectivity indices are topological descriptors of molecular structure based on a count of skeletal atom groupings. The molecular connectivity index is defined [11]:

$${}^m \chi_k = \sum_{j=1}^{n_m} \prod_{i=1}^{m+1} (\delta_i)_j^{-0.5} \quad (1)$$

where *m* is the order of the connectivity index, *k* denotes type of a fragment, which is divided into paths (P), clusters (C), and path/clusters (PC). In formula (1) *n_m* is the number of the relevant paths, and δ_i is equal to the number of non-hydrogen atoms to which the *i*-th non-hydrogen atom is bonded. If δ_i is replaced by δ_i^v , we obtain the expression for the *m*-th order valence connectivity index, ${}^m \chi_k^v$, as follows:

Fig. 1 Chemical structures of the investigated surfactants and their abbreviations.

R₁ = C_nH_{2n+1}
(n = 10, 12, 14, 16),
R₂ = C_nH_{2n+1} (n = 8, 10, 12),
R₃ = C_nH_{2n+1}
(n = 10, 12, 14, 16),
R₄ = C_nH_{2n+1}
(n = 12, 16, 18),
R₅ = C_nH_{2n+1} (n = 8, 10, 12),
R₆ = C_nH_{2n+1} (n = 8, 12)



$${}^m \chi_k^\nu = \sum_{j=1}^{n_m} \prod_{i=1}^{m+1} (\delta_i^\nu)_j^{-0.5} \quad (2)$$

where δ_i^v is defined by

$$\delta^v = \frac{Z^v - h}{Z - Z^v - 1} \quad (3)$$

where Z^v , Z and h are the number of valence electrons, the total number of electrons in the i -th atom, and the number of hydrogen atoms, respectively.

3.2 Correlation formula

The formula expressing the relationship between the $\text{Log}cmc$ and connectivity indices was generated using the least squares method. The statistical calculations were performed using the program *STATISTICA 8.0* [19]. The final models were generated using the methodology described in previous papers [4, 7, 12]. In the process of searching for the equations three criteria were taken into account: a correlation coefficient (r), a Fisher ratio value (F) and a standard error (s). The best relationship is that which has possibly highest values of r and F , and simultaneously the lowest value of s .

4 Results and discussions

In the process of searching for the relationships between cmc and topological descriptors we used, just as in the previous paper [12], ten indices: five connectivity indices (from zeroth to fourth order) and five valence connectivity indices (from zeroth to fourth order). These indices were calculated for the compounds studied using Eqs. 1–3. The calculated connectivity indices are listed in Table 2.

Using a stepwise method we have obtained three models. In each model we start our correlation procedure with one index, i.e. the first step is common for each model and it is presented in Table 3.

We see that the best correlations in the first step are for the relationships containing the first-order valence connectivity index ${}^1\chi^v$ and the zeroth-order valence connectivity index ${}^0\chi^v$. These indices define first steps for Model 1 and Models 2 and 3, respectively.

In the first model the search for the best equation consists of three steps including the first step described above. The result of all correlations is presented in Table 4.

The best correlation in the first step in Model 1 is for the relationship containing the index ${}^1\chi^v$, and we get the following formula:

$$\text{Log}cmc = 1.339 - 0.402 \cdot {}^1\chi^v \quad (4)$$

Next to this index we added the remaining indices separately. The result of the second step is presented in Table 4. Now we see that we get best correlation for the relationship containing in addition to the previous step the index ${}^4\chi_{pc}$ (fourth-order connectivity index). The obtained formula for this step is as follows:

$$\text{Log}cmc = 1.623 - 0.531 \cdot {}^1\chi^v + 0.920 \cdot {}^4\chi_{pc} \quad (5)$$

Table 2 The connectivity indices and the experimental Logcmc values

	$^0\chi$	$^1\chi$	$^2\chi$	$^3\chi_c$	$^4\chi_{pc}$	$^0\chi^v$	$^1\chi^v$	$^2\chi^v$	$^3\chi_c^v$	$^4\chi_{pc}^v$	LogCMC
DMePC	13.814	9.268	7.303	0.927	1.436	13.814	9.268	7.303	0.927	1.436	-1.699
DMeMC	13.814	9.268	7.303	0.927	1.436	13.515	8.845	6.855	0.927	1.436	-1.678
C ₁₀ BEC	13.855	8.454	7.487	1.849	0.961	12.887	7.611	6.433	1.620	0.601	-1.745
C ₁₂ BEC	15.270	9.454	8.194	1.849	0.961	14.301	8.611	7.140	1.620	0.601	-2.260
C ₁₄ BEC	16.684	10.454	8.901	1.849	0.961	15.715	9.611	7.847	1.620	0.601	-2.721
C ₁₆ BEC	18.098	11.454	9.608	1.849	0.961	17.129	10.611	8.554	1.620	0.601	-3.481
C ₁₂ APC	12.891	8.932	6.475	0.204	0.433	12.165	7.971	5.417	0.118	0.219	-1.824
C ₁₆ APC	15.719	10.932	7.889	0.204	0.433	14.993	9.971	6.831	0.118	0.219	-3.046
C ₁₈ APC	17.133	11.932	8.596	0.204	0.433	16.407	10.971	7.538	0.118	0.219	-3.620
C ₁₀ TAC	10.864	6.561	5.786	1.561	0.75	10.864	6.561	5.786	1.561	0.75	-1.215
C ₁₂ TAC	12.278	7.561	6.493	1.561	0.75	12.278	7.561	6.493	1.561	0.75	-1.678
C ₁₄ TAC	13.692	8.561	7.200	1.561	0.75	13.692	8.561	7.200	1.561	0.75	-2.347
C ₁₆ TAC	15.106	9.561	7.907	1.561	0.75	15.106	9.561	7.907	1.561	0.75	-2.854
C ₁₈ TAC	16.521	10.561	8.614	1.561	0.75	16.521	10.561	8.614	1.561	0.75	-3.461
1-8PiC	13.977	9.162	7.591	1.215	1.696	13.009	8.318	6.536	0.986	1.367	-0.928
1-10PiC	15.391	10.162	8.298	1.215	1.696	14.423	9.318	7.243	0.986	1.367	-1.678
1-12PiC	16.805	11.162	9.005	1.215	1.696	15.837	10.318	7.950	0.986	1.367	-2.260
DDAC	11.355	7.270	5.364	0.408	0.289	11.355	7.270	5.364	0.408	0.289	-1.801
C ₈ AC	6.9498	4.414	2.768	0	0	6.9498	4.414	2.768	0	0	-0.699
C ₁₀ AC	8.364	5.414	3.475	0	0	8.364	5.414	3.475	0	0	-1.319
C ₁₂ AC	9.778	6.414	4.182	0	0	9.778	6.414	4.182	0	0	-1.870
ONAC	12.510	8.236	6.593	0.704	1.425	10.745	6.625	4.582	0.26	0.45	-0.658
DNAC	15.338	10.236	8.007	0.704	1.425	13.573	8.625	5.996	0.26	0.45	-1.906

Table 3 The values of the correlation coefficients for first step

Connectivity index	$^0\chi$	$^1\chi$	$^2\chi$	$^3\chi_c$	$^4\chi_{pc}$	$^0\chi^v$	$^1\chi^v$	$^2\chi^v$	$^3\chi_c^v$	$^4\chi_{pc}^v$
Correlation coefficient	0.744	0.731	0.654	0.255	0.118	0.812	0.815	0.736	0.286	0.068

Table 4 The values of the correlation coefficients for each step in the Model 1

Connectivity index	$^0\chi$	$^1\chi$	$^2\chi$	$^3\chi_c$	$^4\chi_{pc}$	$^0\chi^v$	$^1\chi^v$	$^2\chi^v$	$^3\chi_c^v$	$^4\chi_{pc}^v$
STEP 1	0.744	0.731	0.654	0.255	0.118	0.812	0.815	0.736	0.286	0.068
STEP 2	0.826	0.842	0.858	0.820	0.974	0.817		0.818	0.793	0.945
STEP 3	0.983	0.974	0.983	0.983		0.987		0.978	0.980	0.977

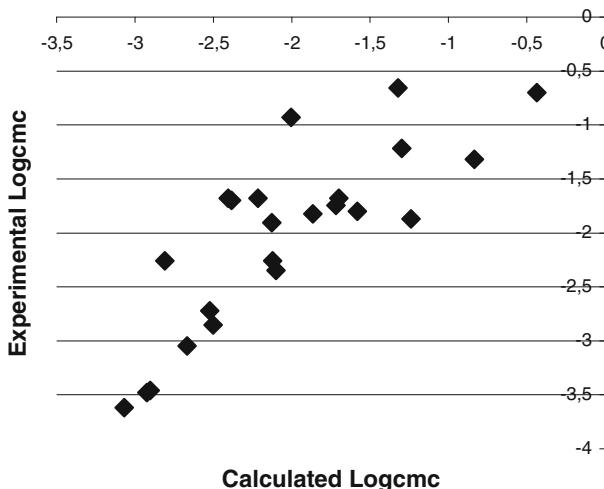


Fig. 2 Scatter plot of the calculated Logcmc versus the experimental Logcmc ($r = 0.815$, $F = 41.59$, $s = 0.5$). Step 1

In the third step the ${}^0\chi^v$ index (zeroth-order valence connectivity index) was added (see Table 4) and the corresponding equation is the following:

$$\text{Logcmc} = 1.820 - 0.083 \cdot {}^1\chi^v + 0.977 \cdot {}^4\chi_{pc} - 0.304 \cdot {}^0\chi^v \quad (6)$$

At this step the process of searching for the best relationship was ended because the further additions of other indices did not change the correlation coefficient significantly.

The process of selecting the best relationship for Model 1 is illustrated in Figs. 2, 3, 4.

When we choose in the first step the zeroth-order valence connectivity index ${}^0\chi^v$, we will obtain Model 2 and Model 3. The second step in these models is common and it is presented in Table 5.

Now we can see that the best correlations in the second step are for the relationships containing the fourth-order connectivity index ${}^4\chi_{pc}$ (Model 2) and the second-order connectivity index ${}^2\chi$ or fourth-order valence connectivity index ${}^4\chi_{pc}^v$ (Model 3).

In second model the search for the best equation consists of two steps including the steps presented in Tables 3 and 5. The result of these correlations is presented in Table 6.

The obtained formula for the first step in Model 2 is:

$$\text{Logcmc} = 1.427 - 0.262 \cdot {}^0\chi^v \quad (7)$$

In the second step the best correlation is for the relationship containing, in addition to the previous step, the ${}^4\chi_{pc}$ index and the obtained formula for that step is:

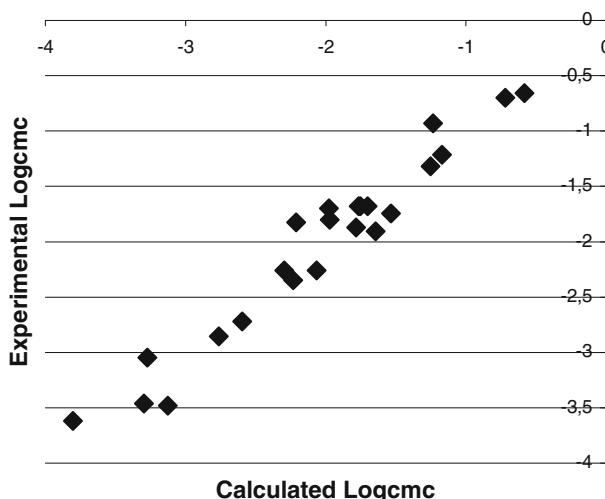


Fig. 3 Scatter plot of the calculated Logcmc versus the experimental Logcmc ($r = 0.974$, $F = 389.01$, $s = 0.196$). Step 2

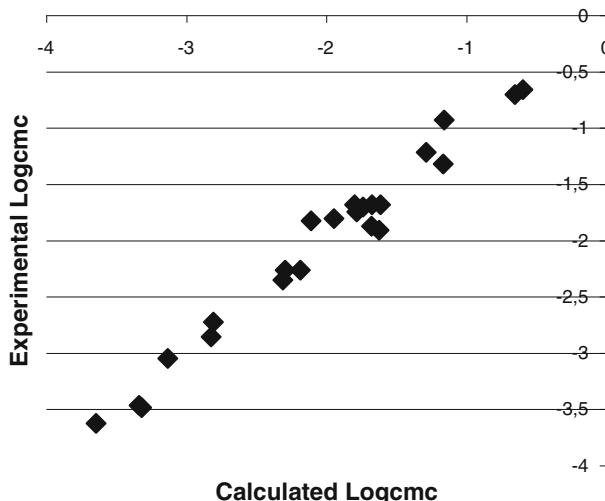


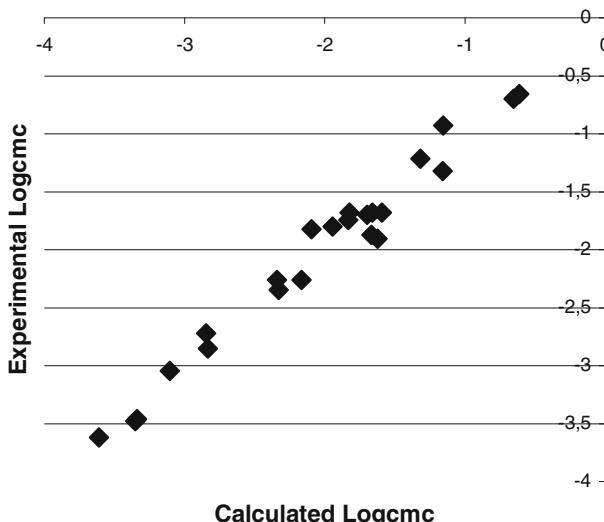
Fig. 4 Scatter plot of the calculated Logcmc versus the experimental Logcmc ($r = 0.987$, $F = 818.46$, $s = 0.137$). Step 3 (final)

Table 5 The values of the correlation coefficients for second step in Model 2 and Model 3

Connectivity index	${}^0\chi$	${}^1\chi$	${}^2\chi$	${}^3\chi_c$	${}^4\chi_{pc}$	${}^1\chi^v$	${}^2\chi^v$	${}^3\chi_c^v$	${}^4\chi_{pc}^v$
Correlation coefficient	0.856	0.826	0.941	0.842	0.987	0.817	0.833	0.826	0.942

Table 6 The values of the correlation coefficients for the steps in the Model 2

Connectivity index	${}^0\chi$	${}^1\chi$	${}^2\chi$	${}^3\chi_c$	${}^4\chi_{pc}$	${}^0\chi^v$	${}^1\chi^v$	${}^2\chi^v$	${}^3\chi_c^v$	${}^4\chi_{pc}^v$
STEP 1	0.744	0.731	0.654	0.255	0.118	0.812	0.815	0.736	0.286	0.068
STEP 2	0.856	0.826	0.941	0.842	0.987		0.817	0.833	0.826	0.942

**Fig. 5** Scatter plot of the calculated Logcmc versus the experimental Logcmc ($r = 0.987$, $F = 787.82$, $s = 0.14$). Step 2 (final)**Table 7** The values of the correlation coefficients for each step in the Model 3

Connectivity index	${}^0\chi$	${}^1\chi$	${}^2\chi$	${}^3\chi_c$	${}^4\chi_{pc}$	${}^0\chi^v$	${}^1\chi^v$	${}^2\chi^v$	${}^3\chi_c^v$	${}^4\chi_{pc}^v$
STEP 1	0.744	0.731	0.654	0.255	0.118	0.812	0.815	0.736	0.286	0.068
STEP 2	0.856	0.826	0.941	0.842	0.987		0.817	0.833	0.826	0.942
STEP 3	0.990	0.965	0.993	0.943	0.988		0.948	0.956	0.943	

$$\text{Logcmc} = 1.832 - 0.358 \cdot {}^0\chi^v + 0.982 \cdot {}^4\chi_{pc} \quad (8)$$

The scatter plot of the logarithm of cmc calculated from Eq. 8 versus the experimental one is shown in Fig. 5.

In Model 3 the search for the best relationship consists of three steps including the steps presented in Tables 3 and 5. The result of these correlations is presented in Table 7.

The result of the first step for Model 3 is presented in Table 7 and the formula for that step is described by Eq. 7. From this table in the second step we get best correlation for the relationship which, in addition to the first step, contains the index ${}^4\chi_{pc}^v$ (fourth-order valence connectivity index). The obtained formula for this step is:

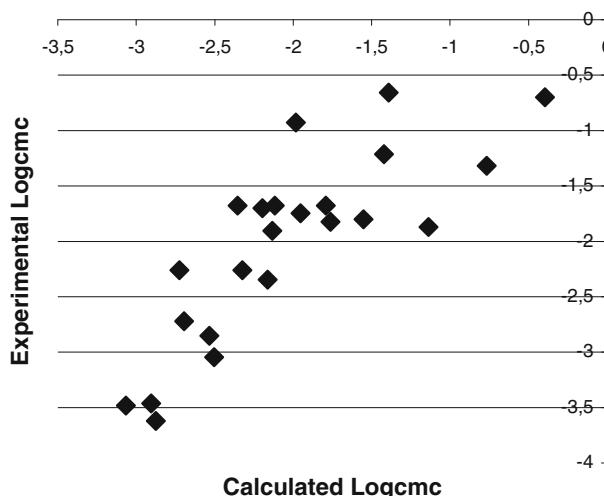


Fig. 6 Scatter plot of the calculated $\text{Log}cmc$ versus the experimental $\text{Log}cmc$ ($r = 0.812$, $F = 40.614$, $s = 0.5$). Step 1

$$\text{Log}cmc = 1.810 - 0.3391 \cdot {}^0\chi^v + 0.961 \cdot {}^4\chi_{pc}^v \quad (9)$$

The best correlation in third step in Model 3 is for the relationship which, in addition to the previous one, contains the index ${}^2\chi$ (second-order connectivity index) and the formula for $\text{Log}cmc$ becomes:

$$\text{Log}cmc = 2.603 - 0.710 \cdot {}^0\chi^v + 0.694 \cdot {}^4\chi_{pc}^v + 0.604 \cdot {}^2\chi \quad (10)$$

The process of selecting the best relationship for Model 3 is illustrated in Figs. 6, 7, 8.

It is worth noting that Model 2 and Model 3 show the best correlations among all the formulae containing two and three indices respectively.

The specification of all models is listed in Table 8.

The calculated logarithm of cmc values using the Models 1–3 and experimental $\text{Log}cmc$ for the surfactants studied are listed in Table 9.

From the previous calculation and from Table 9 it follows that Model 3 is the best, and the calculated values of $\text{Log}cmc$ are very close to the experimental ones. The structures of the compounds used for the correlation are diverse, which allows suggesting that the obtained equation for the prediction of $\text{Log}cmc$ from only topological indices may have quite a general meaning.

It is worth noting that all the models contain ${}^0\chi^v$ index with negative coefficients and ${}^4\chi_{pc}$ or ${}^4\chi_{pc}^v$ with positive ones. Thus, as ${}^0\chi^v$ increases the cmc decreases, and in the case of ${}^4\chi_{pc}$ or ${}^4\chi_{pc}^v$ it is vice versa. This may suggest that the index ${}^0\chi^v$ includes some information about hydrophobicity, while ${}^4\chi_{pc}$ and ${}^4\chi_{pc}^v$ about hydrophilicity of the cationic surfactants studied.

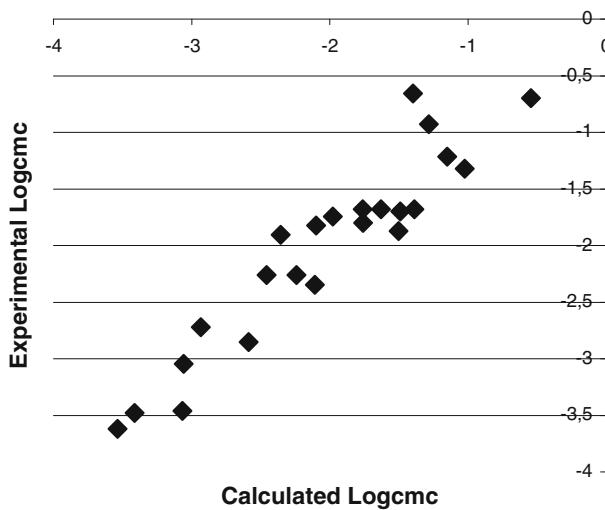


Fig. 7 Scatter plot of the calculated Logcmc versus the experimental Logcmc ($r = 0.942$, $F = 165.895$, $s = 0.29$). Step 2

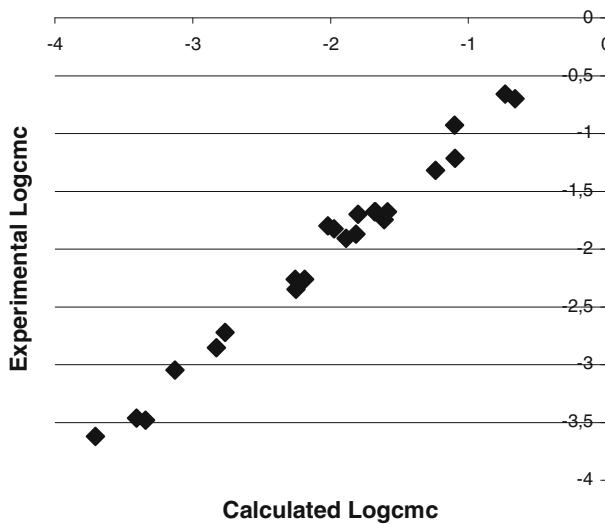


Fig. 8 Scatter plot of the calculated Logcmc versus the experimental Logcmc ($r = 0.993$, $F = 1477.17$, $s = 0.102$). Step 3 (final)

Table 8 Specification of Models 1–3

ModelRelationship

1	$\text{Logcmc} = 1.820 - 0.083 \cdot {}^1\chi^v + 0.977 \cdot {}^4\chi_{pc} - 0.304 \cdot {}^0\chi^v$
2	$\text{Logcmc} = 1.832 - 0.358 \cdot {}^0\chi^v + 0.982 \cdot {}^4\chi_{pc}$
3	$\text{Logcmc} = 2.603 - 0.710 \cdot {}^0\chi^v + 0.694 \cdot {}^4\chi_{pc}^v + 0.604 \cdot {}^2\chi$

Table 9 Calculated and literature values of Log cmc for studied 23 cationic surfactants

Compound	Experimental Log cmc	Calculated Log cmc		
		Model 1	Model 2	Model 3
DMePC	−1.699	−1.740	−1.698	−1.799
DMeMC	−1.678	−1.615	−1.591	−1.587
C ₁₀ BEC	−1.745	−1.786	−1.833	−1.61
C ₁₂ BEC	−2.260	−2.298	−2.339	−2.187
C ₁₄ BEC	−2.721	−2.810	−2.845	−2.764
C ₁₆ BEC	−3.481	−3.322	−3.351	−3.341
C ₁₂ APC	−1.824	−2.112	−2.094	−1.974
C ₁₆ APC	−3.046	−3.136	−3.105	−3.128
C ₁₈ APC	−3.620	−3.649	−3.611	−3.705
C ₁₀ TAC	−1.215	−1.290	−1.317	−1.097
C ₁₂ TAC	−1.678	−1.803	−1.823	−1.674
C ₁₄ TAC	−2.347	−2.315	−2.328	−2.251
C ₁₆ TAC	−2.854	−2.827	−2.834	−2.829
C ₁₈ TAC	−3.461	−3.340	−3.34	−3.407
1-8PiC	−0.928	−1.163	−1.155	−1.101
1-10PiC	−1.678	−1.676	−1.661	−1.679
1-12PiC	−2.260	−2.188	−2.166	−2.256
DDAC	−1.801	−1.948	−1.945	−2.021
C ₈ AC	−0.699	−0.656	−0.653	−0.661
C ₁₀ AC	−1.319	−1.168	−1.159	−1.238
C ₁₂ AC	−1.870	−1.681	−1.665	−1.816
ONAC	−0.658	−0.600	−0.611	−0.733
DNAC	−1.906	−1.625	−1.623	−1.888

The obtained relationships were used to predict Log cmc for some cationic surfactants which were not used in the correlations. In Table 10 the predicted Log cmc values were compared with the experimental ones.

The agreement between calculated and experimental Log cmc values seems to be quite good and is the best for Model 3. This confirms the usefulness of the obtained correlation for predicting Log cmc for cationic surfactants having chloride as counterion.

5 Conclusion

Relationships between molecular connectivity indices and critical micelle concentration (cmc) of cationic surfactants, mainly quaternary ammonium chloride salts with one hydrophobic tail, were investigated using the quantitative structure—property relationship approach. Three models containing $^0\chi^v$ and $^4\chi_{pc}$ or $^4\chi_{pc}^v$ indices were

Table 10 Test Models 1–3

Compounds	Experimental Log cmc [Ref.]	Calculated Log cmc		
		Model 1	Model 2	Model 3
DM-11 Cl[−] 	−2.022 [20]	−2.111	−2.151	−2.036
JOJ-N⁺H₃ Cl[−] 	−3.745 [21]	−2.859	−2.841	−3.072

obtained. The ${}^0\chi^v$ index is with negative while the ${}^4\chi_{pc}$ and ${}^4\chi_{pc}^v$ indices are with positive coefficients. It is suggested that the index ${}^0\chi^v$ includes some information about hydrophobicity while indices ${}^4\chi_{pc}$ and ${}^4\chi_{pc}^v$ include some information about hydrophilicity of the cationic surfactants studied. The best model contains ${}^0\chi^v$ and ${}^4\chi_{pc}$ indeces and also ${}^2\chi$ index. The obtained relationship should enable to predict the cmc of cationic surfactants with chloride as counterion.

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